

Electronic Degeneracy and Intrinsic Magnetic Properties of Epitaxial Nb: SrTiO₃ Thin Films Controlled by Defects

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We report thermoelectric power experiments in *e*-doped thin films of SrTiO₃ (STO) which demonstrate that the electronic band degeneracy can be lifted through defect management during growth. We show that even small amounts of cationic vacancies, combined with epitaxial stress, produce a homogeneous tetragonal distortion of the films, resulting in a Kondo-like resistance upturn at low temperature, large anisotropic magnetoresistance, and nonlinear Hall effect. *Ab initio* calculations confirm a different occupation of each band depending on the degree of tetragonal distortion. The phenomenology reported in this Letter for tetragonally distorted *e*-doped STO thin films, is similar to that observed in LaAlO₃/STO interfaces and magnetic STO quantum wells.

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The possibility of growing epitaxial interfaces with atomic precision leads to unexpected functionalities in polar interfaces between oxide insulators [1–3]. In particular, the two-dimensional electron gas (2DEG) emerging at the interface between SrTiO₃ (STO) and LaAlO₃ (LAO) [4,5], can be tuned to produce a very rich phase diagram, including magnetism and superconductivity [6,7]. These properties are common to the 2DEGs stabilized at the bare surface of bulk STO, and are derived to a large extent from the arrangement and filling of the Ti-*t_{2g}*-derived subbands close to the conduction band minimum [8–11]. This orbital reconstruction can be intrinsic, to cancel the electrostatic energy of the polar interface [12], but could also be caused by the structural distortions and atomic vacancies which relax the epitaxial strain in these thin-film heterostructures. However, the effect of cationic and anionic vacancies on the transport properties of both STO [13] and LAO/STO interfaces [14] is mostly considered from the point of view of their acceptor or donor nature over the total charge density, although vacancies distribute along the crystal structure expanding the unit cell due to an increased Coulomb repulsion [15]. In the case of epitaxial thin films below a certain critical thickness, this has to be necessarily accommodated purely as an increase of the *c*-axis parameter, due to the clamping of the in-plane lattice parameters to the substrate [16]. In this case, if the tetragonal distortion is homogeneous throughout the film instead of localized around defects, an important effect over the band structure can be anticipated.

Here we show that the formation of cation or anion vacancies during epitaxial growth results in a homogeneous

tetragonal distortion along the films, which determines their transport properties. *Ab initio* calculations and thermoelectric power experiments under different degrees of stress suggest that the band degeneracy characteristic of STO can be lifted for sufficiently distorted films. A resistance upturn at low temperature, large anisotropic magnetoresistance (AMR), and a nonlinear Hall effect are observed. This phenomenology was previously observed in LAO/STO interfaces and magnetic STO quantum wells [17,18]. Here we demonstrate that it can also be observed in electron-doped STO thin films under a sufficiently large tetragonal distortion.

Epitaxial thin films of Nb doped SrTiO₃ (Nb:STO) were grown by Pulsed Laser Deposition (PLD) (KrF, $\lambda = 248$ nm, laser fluence 0.9 J/cm², 5 Hz, at 800 °C) on top of (001) TiO₂-terminated STO ($a = 3.905$ Å), and (001) (LaAlO₃)_{0.3}(SrAlTaO₆)_{0.7} (LSAT, $a = 3.87$ Å) substrates. The oxygen pressure was varied from 10⁻² to 200 mTorr. After deposition the samples were cooled at the same oxygen pressure. The conditions were optimized to obtain layer-by-layer growth, even in films as thick as ≈ 50 nm (see Supplemental Material [19]).

Growing stoichiometric films of STO by PLD is only possible in a very narrow range of laser fluence, oxygen pressure and temperature [15,16,29–33]. Away from this window, the samples always present a varying amount of cationic and anionic vacancies, which produce a substantial enlargement of the unit cell [29]. The effect of oxygen pressure on the microstructure of the films studied in this work is summarized in Figs. 1 and 2. As expected, reducing

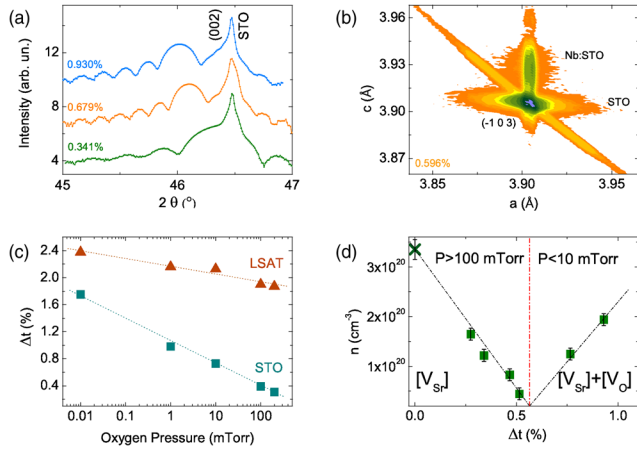


FIG. 1 (color online). (a) XRD patterns of 25(1) nm thick Nb:STO films grown on (001) STO, at different oxygen pressures. Numbers indicate the percentage of tetragonal distortion Δt . (b) High resolution reciprocal space map around the (-103) reflection, for one film deposited at 1 mTorr. (c) Pressure dependence of the tetragonal distortion for thin films deposited on STO and LSAT. (d) Room temperature carrier density as a function of the tetragonal distortion, determined from Hall effect for samples deposited on STO. The cross corresponds to the theoretical value expected for the nominal Nb doping.

the pressure results in a substantial increase of the c -axis lattice parameter [Fig. 1(a)] [34]. However, our study adds some important findings to previous works: x-ray analysis shows that the epitaxial films grow fully strained at all pressures [Fig. 1(b)]. High angle annular dark field scanning transmission electron microscopy (HAADF STEM) and geometrical phase analysis (GPA) show that the expansion of the c -axis parameter is homogeneous along the film thickness, even for 50 nm thick films [Fig. 2(h)], not influenced by the presence of clustered defects.

Therefore, it can be concluded that there is a homogeneous tetragonal distortion of the unit cell as the oxygen pressure is decreased. This distortion can be quantified by $\Delta t = (c_f - a_s) \times 100/a_s$, where f , and s stand for film and substrate, respectively.

At first sight it is tempting to ascribe the distortion to the presence of oxygen vacancies, V_O . However, postannealing of the films in oxygen resulted in a negligible variation of the lattice parameter (see Supplemental Material [19]), or even a slight increase [35]. Therefore, V_O cannot be the main source of this expansion. Other possible sources of expansion could be the formation of defects due to bombardment of the film with highly energetic ions during deposition [36,37], or the presence of cationic vacancies [16,33,35,38]. In the range of laser fluence and oxygen pressures used in this work, Sr vacancies (V_{Sr}) are energetically favored over V_{Ti} [31]. We performed XPS analysis to determine the stoichiometry of our samples, and confirmed an increasing amount of Sr vacancies as oxygen pressure decreases (see Supplemental Material [19]). Within the resolution of our analysis, the samples grown at 100–200 mTorr are nearly stoichiometric, and the amount of V_{Sr} increases to $\approx 5\%$ – 7% at lower pressures. The analyses also confirm the equal amount of Nb [$\approx 1.8(1)\%$] in all samples. Therefore, although the presence of V_O is expected to be increasingly important as the oxygen pressure decreases, we conclude that the major contribution to the lattice expansion in the whole pressure range is due to doubly charged V_{Sr} . It is very interesting that a small concentration of cationic vacancies is able to produce a homogeneous tetragonal distortion of the whole film, as shown in Fig. 2.

The increasing influence of oxygen vacancies in the whole pressure range can be further studied by the Hall effect, given the different nature of V_{Sr} (e acceptor), [39] and V_O (e donor) over the total charge density.

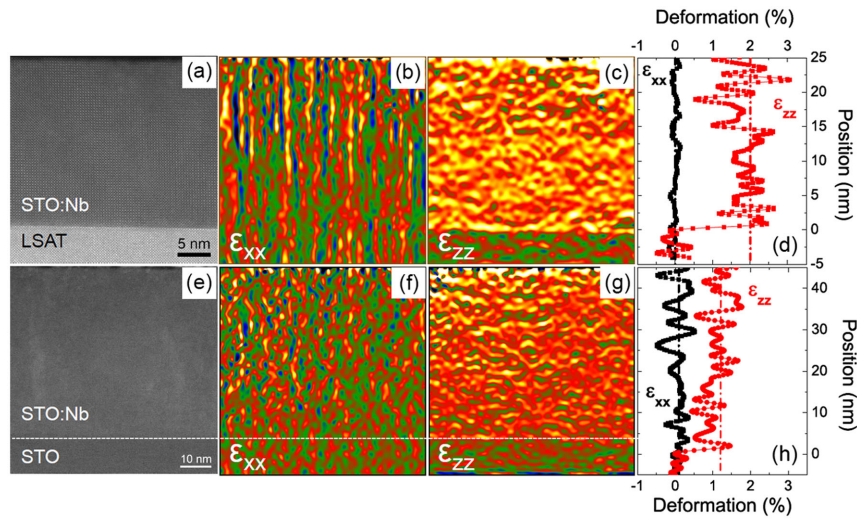


FIG. 2 (color online). HAADF-STEM image of Nb:STO thin films deposited on STO (e) and LSAT (a). GPA analysis showing the in-plane ϵ_{xx} (b, f) and out of plane ϵ_{zz} (c, g) elongation, with respect to the substrate. A profile along the film thickness is shown in panels (d) and (h). The analysis indicates a homogeneous tetragonal distortion $\Delta t \approx 1.5\%$ for STO and $\approx 2.5\%$ for LSAT.

The electronic density determined by Hall measurements at room temperature is shown in Fig. 1(d) for a series of films deposited on STO. In agreement with the previous discussion, the charge density shows two distinct regimes as a function of Δt : for samples grown at high oxygen pressure the carrier density decreases continuously from the expected nominal value, reflecting the presence of electron-trapping defects.

Besides, growing samples below ≈ 10 mTorr results in an increase of the carrier density, showing the important contribution of oxygen vacancies to the electronic transport below this pressure range.

Therefore, there is a continuous change in the nature of vacancies as a function of the oxygen pressure. However, while they show an opposite contribution to the resistivity, only V_{Sr} produce a significant contribution to the tetragonal distortion of the lattice.

Also, the analysis of the structural and microstructural data shows a different volume for the films grown on STO and LSAT [Fig. 1(c)], demonstrating a dependence of the unit-cell expansion on the epitaxial stress. Although growing Nb:STO on LSAT introduces a moderately compressive stress ($\approx 0.9\%$), the continuous increase of the c -axis parameter with decreasing oxygen pressure is totally unexpected, on the basis of Poisson's effect in a stoichiometric system.

Once the existence of a homogeneous tetragonal distortion was established, we studied its effect on the electronic band structure of the system. We have performed density functional theory-based calculations [40,41] on bulk STO under various degrees of tetragonal distortion $\Delta t \approx 0\% - 3\%$ (allowing for octahedral rotations).

Spin-orbit coupling splits the t_{2g} states (effectively an $l = -1$ triplet) [42] at the Γ point, into a low-lying doublet and an upper lying singlet [see Fig. 3(a) where the band structure for $\Delta t = 2\%$ is shown]. The additional tetragonal distortion splits the doublet, the so-called $j_{\text{eff}} = 3/2$ states, which in the cubic case are two Kramers doublets. In order to analyze the evolution of the occupation of the different bands as Δt increases, we focused on the number of electrons with d_{xy} symmetry (n_{xy}) as a function of the total carriers [this was done assuming all the carriers in the unit cell are t_{2g} electrons ($xy + xz + yz$)]. The on-site energy of the d_{xy} electrons increases with Δt , as they are relatively destabilized by the octahedral elongation with respect to the $d_{xz,yz}$. Therefore, a reduction of the relative weight of the xy electrons is anticipated from the calculations as Δt and n increase, thus reducing the overall electron degeneracy inside the t_{2g} manifold. This trend is observed in Fig. 3(b), in the range of doping relevant for comparison with our experiments.

The impact of this change in the band structure and occupation can be tested experimentally from the temperature dependence of the Seebeck coefficient, for samples under different degrees of distortion. Given the band structure of STO, a good approximation for the thermoelectric power of carriers at the bottom of its conduction

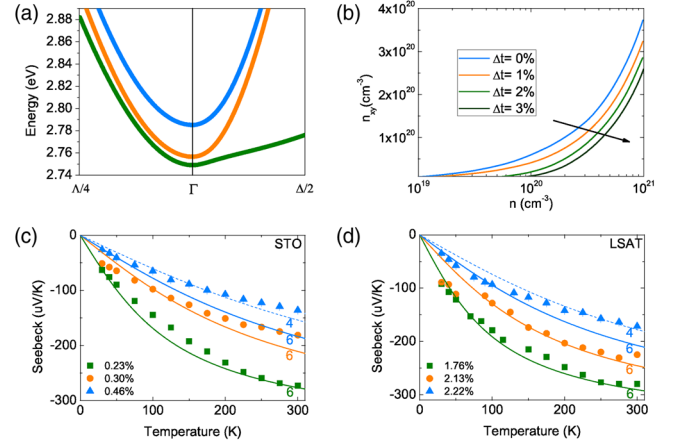


FIG. 3 (color online). (a) Band structure of bulk STO under a tetragonal distortion $\Delta t = 2\%$ with the upper band split by spin-orbit coupling. The low-lying doublet is split as a result of the tetragonal distortion. (b) Total number of electrons with d_{xy} symmetry as a function of the total number of d electrons, which decreases as the tetragonal distortion increases. (c) Temperature dependence of the Seebeck coefficient for thin films deposited on STO and (d) LSAT, for different Δt . The lines are calculations from Eq. (1).

band could be derived from the Boltzmann equation for a parabolic band (z -fold degenerate) [43]:

$$S = \left(\frac{k_B}{e} \right) [-y + \delta_r(y)], \quad (1)$$

$$\delta_r(y) = \frac{(r+2)F_{r+1}(y)}{(r+1)F_r(y)}, \quad (2)$$

where $y = (\mu/k_B T)$ is the reduced chemical potential, r is the scattering parameter for the energy-dependent relaxation time, $\tau(E) = \tau_0 E^r$, which for charged impurities can be taken to be $3/2$ [44–46], and F_r is the Fermi integral. Using the experimental values of the charge density measured by the Hall effect, an average $m^* = 1.5m_e$, taken from Shubnikov–de Haas [47,48] and the following relation to calculate the chemical potential:

$$n = z \left(\frac{2\pi m^* k_B T}{h^2} \right)^{3/2} \frac{2}{\sqrt{\pi}} F_{1/2}(y), \quad (3)$$

the thermoelectric power can be calculated from Eq. (1), taking the band degeneracy z as the only adjustable parameter. The results of the calculation are shown in Figs. 3(c) and 3(d), along with the experimental data. There is a very good agreement between the calculation and the experimental data. But it is also clear from these plots that films with larger Δt fit better to the curves with $z = 4$, in both STO and LSAT, while the films grown at higher oxygen pressures (Δt small) fit better to the $z = 6$ curve.

Therefore, thermoelectric power and *ab initio* calculations support a scenario in which an additional band splitting

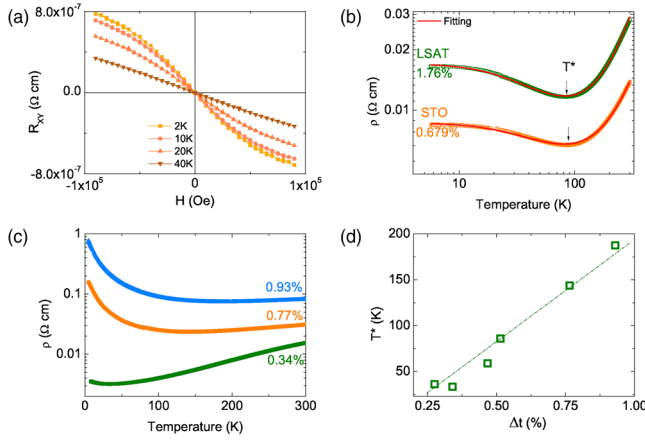


FIG. 4 (color online). (a) Hall resistivity at different temperatures. The nonlinear behavior at high field disappears above T^* . (b) The resistivity for two samples grown at the same oxygen pressure on different substrates, indicating the T^* and the corresponding Δt . The solid line represents the fitting to the Kondo equation (see Supplemental Material [19]). (c) Temperature dependence of the resistivity for Nb:STO thin films deposited on STO substrates at different oxygen pressures (resulting in a different tetragonal distortion). (d) Variation of T^* , as a function of the tetragonal distortion Δt .

is produced in Nb:STO due to the presence of V_{Sr} , whose amount is extremely sensitive to deposition conditions. Moving the Fermi energy across these bands will change the relative contribution from heavy or light electrons to the transport properties of the system. Actually, a change from one- to two-carrier transport has been suggested at a universal critical density in LAO/STO interfaces [49,50]. Particularly, due to the contribution of lower mobility carriers at large fields, this results in a nonlinear contribution to the Hall effect at low temperatures.

The Hall data are shown in Fig. 4(a) for one of our films with $\Delta t = 0.68\%$. At low temperature there is a clear deviation from the low-field linear behavior, similar to observations in LAO/STO interfaces [49,50].

This behavior is observed up to a given temperature T^* , which marks a minimum in the temperature dependence of the resistivity. An upturn and saturation in the low temperature resistivity as shown in Fig. 4(b) was previously reported in electrolyte-gated STO, associated to the Kondo effect from local Ti^{3+} magnetic moments [20,51]. However, as shown in Fig. 4(c), T^* increases linearly with Δt , showing that the change in the conduction mechanism at low temperature is determined by the total concentration of defects. This, along with the absence of any anomaly in the Seebeck coefficient at the Kondo temperature, suggests that in this case the transition to a thermally activated behavior observed below T^* is most probably due to conventional vacancy scattering, and not to the Kondo effect.

On the other hand, a nonlinear Hall effect could be due to an anomalous contribution from a magnetically ordered

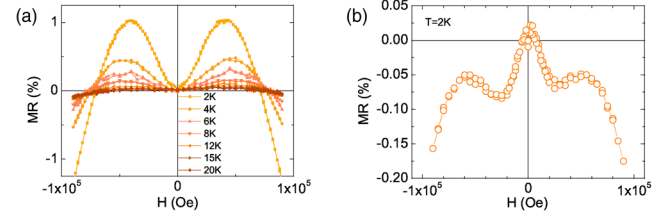


FIG. 5 (color online). (a) Anisotropic magnetoresistance, for a 50 nm thick film deposited on STO at 10 mTorr ($\Delta t \approx 0.68\%$). The magnetic field is applied in the plane of the film, perpendicular to the current. (b) Magnetoresistance of the same film measured at 2 K, with the magnetic field applied perpendicular to the surface of the film.

phase [52]. In fact, the presence of localized magnetic moments and magnetic order in doped STO and LAO/STO interfaces is a controversial issue, whose origin is still under discussion [6,53–55].

An important test for the presence of localized magnetic moments and spontaneous magnetic ordering will come from the study of the AMR. Below T^* , the transverse MR [H in plane, perpendicular to the current, Fig. 5(a)] shows a change of sign at ≈ 5 T, while the perpendicular MR [H out of plane, Fig. 5(b)] is a nonmonotonically decreasing function of H . This behavior is in principle compatible with a weak anti-localization (WAL) contribution to the resistivity in the presence of a strong spin-orbit coupling [48]. However, we have observed this behavior in 50 nm thick, highly distorted films. Moreover, the anisotropy in the MR (see Supplemental Material [19]), suggests that the source of this spin-orbit scattering is a magnetic phase, rather than independent magnetic moments (isotropic) at Ti^{3+} sites. We want to remark that a very similar behavior was observed in STO quantum wells embedded in antiferromagnetic $SmTiO_3$, ascribed to a magnetic proximity effect, [18] as well as in LAO/STO interfaces [17]. Also, although Fe impurities are normally associated to Ti , the fact that the MR is observed below a minimum which depends on strain and not only on the composition of the films, makes it highly improbable that the AMR effect is related to the presence of magnetic Fe impurities in the films.

In summary, we have demonstrated that even a small concentration of cationic defects in epitaxial thin films of electron-doped STO produce a homogeneous tetragonal distortion of the system. This has a profound impact on the electronic band degeneracy and therefore on the magnetotransport properties, as we have shown by combining thermopower measurements and *ab initio* calculations. On the other hand, a nonlinear contribution to the Hall effect, and anisotropic MR compatible with a magnetically ordered phase, has been observed in distorted thin films at low temperature. Therefore, our results show that a similar phenomenology to that of LAO/STO interfaces and quantum wells can be achieved in *e*-doped STO thin films, after proper control of cationic vacancies during growth.

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